

[ABSTRACT]

A resist composition that contains an alkali-soluble resin having a constitutional unit represented by General Formula (a10-1) and a constitutional unit represented by General Formula (a20-1) and has a LogP value of 2.8 or less, a compound (B0) having a molar absorption coefficient of $10,000 \text{ mol}^{-1} \cdot \text{L} \cdot \text{cm}^{-1}$ or less at a wavelength of 248 nm, and a crosslinking agent, where the resist composition has a concentration of solid contents of 15% by mass or more, R^{x1} and R^{x2} represent a hydrogen atom, Y^{ax1} and Y^{ax2} represent a single bond or a divalent linking group, W^{ax1} represents an aromatic hydrocarbon group which may have a substituent, n_{ax1} represents an integer of 1 or more,

10 R^{ax2} represents a hydrocarbon group.

